

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	62	wafer with mark\$3 with position\$3 with parameter\$3 with measur\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/30 08:10
S1	56	wafer with pattern with project\$4 with (flat or notch)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/10/14 09:43
S4	6	wafer with pattern with project\$4 with (flat or notch) with position and exposure	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/10/14 07:48